IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of) Examiner: Mic	hael Lebentritt
AKIRA UNNO ET AL.)	
Application No.: NYA Division of U.S. Appln. No. 10/068,988, filed February 11, 2002	: Group Art: 282) :)	4
Filed: Concurrently Herewith) ;	
For: SEMICONDUCTOR SUBSTRATE, SOI SUBSTRATE AND MANUFACTURING METHOD THEREFOR);) :) October 27, 20	03

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

PRELIMINARY AMENDMENT, CLAIM TO PRIORITY AND INFORMATION DISCLOSURE STATEMENT

Sir:

Prior to calculation of the filing fee, and prior to examination on the merits, please amend the above-identified application as follows. The specification changes begin at page 2, the claims changes are reflected in the listing that begins at page 3, and the Remarks begin at page 5.